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IN THE CLAIMS

Claims 1-17: Canceled.

- 18. (Previously Presented) A planarization composition, consisting of: an o-cresol-based polymer compound and a resol phenolic resin; at least one surfactant; and a solvent system.
- (Currently Amended) The planarization composition of claim 18, wherein the ocresol-based polymer compound [[comprises]] is a novolac polymer.
- (Previously Presented) The planarization composition of claim 76, wherein the at least one alcohol comprises a branched alcohol.
- (Currently Amended) The planarization composition of claim 20, wherein the branched alcohol [[comprises]] is 2-propanol.
- (Previously Presented) The planarization composition of claim 76, wherein the at least one ether acetate-based solvent comprises propylene glycol methylether acetate (PGMEA).
- 23. Canceled.
- (Previously Presented) The planarization composition of claim 18, wherein the surfactant comprises at least one non-fluorinated surfactant, at least one fluorocarbon-based surfactant or a combination thereof.
- (Previously Presented) The planarization composition of claim 24, wherein the at least one fluorocarbon-based surfactant comprises at least one fluoroaliphatic polymeric ester surfactant.
- (Previously Presented) A film comprising the planarization composition of claim 18, wherein at least some of the solvent system is removed.

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 (Previously Presented) A film comprising the planarization composition of claim 24, wherein at least some of the solvent system is removed.

Claims 28-29: Canceled.

(Original) A layered component, comprising:

a substrate having a surface topography; and

a planarization composition of claim 18, wherein the composition is coupled to the substrate.

- (Original) The layered component of claim 30, further comprising at least one additional layer of material or film.
- 32. (Original) A layered component, comprising:
 - a substrate having a surface topography; and

a layer comprising the film of claim 26, wherein the layer is coupled to the substrate.

- (Original) The layered component of claim 32, further comprising at least one additional layer of material or film.
- 34. (Original) A layered component, comprising:

a substrate having a surface topography; and

a layer comprising the film of claim 27, wherein the layer is coupled to the substrate

- (Original) The layered component of claim 34, further comprising at least one additional layer of material or film.
- (Currently Amended) A method of forming a planarization composition, consisting of:

providing an o-cresol-based polymer compound and a resol phenolic resin as a structural constituent;

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providing at least one surfactant;

providing a solvent system, wherein the solvent system comprises at least one

alcohol and at least one other acetate-based solvent; and

blending the structural constituent, the at least one surfactant and the solvent

system to form a planarization composition.

Claims 37-40: Canceled.

41. (Currently Amended) The method of claim 77, wherein the alcohol-based solvent

[[comprises]] is 1-propanol or 2-propanol.

 (Previously Presented) The method of claim 36, wherein the solvent system comprises propylene glycol methyl ether acetate (PGMEA), ethyl lactate, propylene

glycol methyl ether, diethylene glycol, 2-propanol, acetone or a combination thereof.

Claims 43-46: Canceled.

 $47. \qquad \hbox{(Original) The method of claim 36, wherein the planarization composition comprises } \\$

an apparent viscosity.

48. (Previously Presented) The method of claim 47, wherein the solvent system lowers

the apparent viscosity by at least 10%.

 $49. \hspace{0.5cm} \hbox{(Original) The method of claim 48, wherein the solvent system lowers the apparent} \\$

viscosity by at least 30%.

50. Canceled.

51. (Previously Presented) The method of claim 36, wherein the surfactant comprises at

least one non-fluorinated_surfactant, at least one fluorocarbon-based surfactant or a

combination thereof.

52. (Previously Presented) The method of claim 51, wherein the at least one

fluorocarbon-based surfactant comprises at least one fluoroaliphatic polymeric ester

surfactant.

53. (Previously Presented) A method of forming a film, comprising:

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providing the planarization composition of claim 18; and

evaporating at least part of the solvent system to form a film.

 (Original) The method of claim 53, wherein evaporating at least part of the solvent system comprises applying a continuous source to the planarization composition.

55. (Original) The method of claim 54, wherein the continuous source comprises a heat

source.

 (Original) The method of claim 55, wherein the continuous source comprises an infrared source, an ultraviolet source, an electron-beam source and combinations

thereof.

Claims 57-75: Canceled.

 (Currently Amended) The planarization composition of claim 18, wherein the solvent system [[includes]] consists of at least one alcohol and at least one ether

acetate-based solvent.

77. (Currently Amended) The method of claim 36, wherein the solvent system

[[includes]] consists of at least one alcohol and at least one ether acetate-based

solvent.

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